

UNITED STATES PATENT AND TRADEMARK OFFICE

Cen

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/710,599	07/23/2004	Chia-Te Lin	13304-US-PA	4598
31561 7590 01/31/2008 JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE 7 FLOOR-1, NO. 100			EXAMINER	
			MCPHERSON, JOHN A	
ROOSEVELT ROAD, SECTION 2 TAIPEI, 100			ART UNIT	PAPER NUMBER
TAIWAN			1795	
				<u></u>
			NOTIFICATION DATE	DELIVERY MODE
		•	01/31/2008	ELECTRONIC

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Notice of the Office communication was sent electronically on above-indicated "Notification Date" to the following e-mail address(es):

USA@JCIPGROUP.COM.TW

1	Application No.	Applicant(s)			
Office Action Summers	10/710,599	LIN ET AL.			
Office Action Summary	Examiner	Art Unit			
	John A. McPherson	1795			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).					
Status					
1) Responsive to communication(s) filed on 15 No	ovember 2007.				
2a)⊠ This action is FINAL . 2b)☐ This	action is non-final.				
3) Since this application is in condition for allowan					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
4) Claim(s) 1,4-6,9 and 10 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 1,4-6,9 and 10 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement.					
Application Papers					
 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. 					
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s)					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	te			

DETAILED ACTION

Response to Amendment

- 1. This Office Action is responsive to the Amendment filed 11/15/07.
- 2. The Amendment filed 11/15/07 successfully overcomes the rejections set forth in paragraph 2 of the Office Action mailed 5/7/07. Accordingly, this rejection is withdrawn.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 4-6, 9 and 10 are rejected under 35 U.S.C. 102(b) as being anticipated by JP 11-087676 for the reasons of record as set forth in paragraph 1 of the Office Action mailed 5/7/07, and as further discussed below.

Response to Arguments

4. Applicant's arguments filed 11/15/07 have been fully considered but they are not persuasive.

With respect to the rejection over JP '676, Applicant argues that this reference fails to disclose the features that the second photoresist layer exposes the filter material

Application/Control Number: 10/710,599

Art Unit: 1795

layer over the first photoresist layer, and the filter material layer over the first photoresist layer is removed before the first and second photoresist layer are removed.

Specifically, Applicant argues that JP '676 discloses a second resist layer is formed for embedding the opening to planarize a surface of the pigment layer, and the second photoresist layer covers the pigment layer rather than exposes the pigment layer, as recited in the amended claims. Furthermore, Applicant argues that the pigment layer cannot be removed before the second photoresist layer is removed since the second photoresist layer covers the pigment layer

However, it is the position of the Examiner that JP '626 does disclose the step of forming a second photoresist layer over the filter material layer within the opening and exposing the filter material layer over the first photoresist layer. Specifically, after the second resist layer **15** is formed embedding the openings and planarizing the surface, it is etched evenly to expose the first resist **12**. As the second resist is etched evenly down to the first resist, it passes through a point where the upper surface of the pigment layer **14** is exposed, and then etching continues until the upper surface of first resist is reached, such that the embedded portion of the second resist remains. See Figure 1(c). Therefore, the second resist is formed embedded within the opening, with the upper surface of the pigment layer exposed by the etching process.

The etching process then continues, so as to remove the pigment layer overlying the first resist, as it proceeds to the surface of the first resist. Finally, the first resist and the embedded portions of the second resist are dissolved in a solvent to remove them.

See the abstracts and Figure 1(d). Therefore, the pigment layer overlying the first resist

layer is removed before the first photoresist layer and the embedded portion of the second layer, although the Examiner notes that the method steps of the presently claimed invention are not limited to any specified order.

Conclusion

5. **THIS ACTION IS MADE FINAL.** Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to John A. McPherson whose telephone number is (571) 272-1386. The examiner can normally be reached on Monday through Friday, 8:00 AM to 4:30 PM.

Art Unit: 1795

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Mark Huff can be reached on (571) 272-1385. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 576-272-1000.

John A. McPherson Primary Examiner Art Unit 1795

JAM 1/23/08